

**§ 469.16**

**SUBPART A—SEMICONDUCTOR BAT EFFLUENT LIMITATIONS**

| Pollutant or pollutant property | Maximum for any 1 day | Average of daily values for 30 consecutive days |
|---------------------------------|-----------------------|---|
|                                 |                       | Milligrams per liter (mg/l)                     |
| TTO <sup>1</sup> .....          | 1.37                  | ( <sup>2</sup> )                                |
| Fluoride (T) .....              | 32.0                  | 17.4  |

<sup>1</sup> Total toxic organics.  
<sup>2</sup> Not applicable.

**§ 469.16 Pretreatment standards for existing sources (PSES).**

Except as provided in 40 CFR 403.7 and 403.13, any existing source subject to this subpart which introduces pollutants into a publicly owned treatment works must comply with 40 CFR part 403 and achieve the following pretreatment standards for existing sources (PSES):

(a)

**SUBPART A—SEMICONDUCTOR PSES EFFLUENT LIMITATIONS**

| Pollutant or pollutant property | Maximum for any 1 day | Average of daily values for 30 consecutive days |
|---------------------------------|-----------------------|---|
|                                 |                       | Milligrams per liter (mg/l)                     |
| TTO <sup>1</sup> .....          | 1.37                  | ( <sup>2</sup> )                                |

<sup>1</sup> Total toxic organics.  
<sup>2</sup> Not applicable.

(b) An existing source submitting a certification in lieu of monitoring pursuant to § 469.13 (c) and (d) of this regulation must implement the solvent management plan approved by the control authority.

**§ 469.17 New source performance standards (NSPS).**

Any new source subject to this subpart must achieve the following new source performance standards (NSPS).

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**SUBPART A—SEMICONDUCTOR NSPS EFFLUENT LIMITATIONS**

| Pollutant or pollutant property | Maximum for any 1 day | Average of daily values for 30 consecutive days |
|---------------------------------|-----------------------|---|
|                                 |                       | Milligrams per liter (mg/l)                     |
| TTO <sup>1</sup> .....          | 1.37                  | ( <sup>2</sup> )                                |
| Fluoride (T) .....              | 32.0                  | 17.4  |
| pH .....                        | ( <sup>2</sup> )      | ( <sup>3</sup> )                                |

<sup>1</sup> Total toxic organics.  
<sup>2</sup> Not applicable.  
<sup>3</sup> Within the range of 6.0 to 9.0.

**§ 469.18 Pretreatment standards for new sources (PSNS).**

Except as provided in 40 CFR 403.7, any new source subject to this subpart which introduces pollutants into a publicly owned treatment works must comply with 40 CFR part 403 and achieve the following pretreatment standards for new sources (PSNS):

(a)

**SUBPART A—SEMICONDUCTOR PSNS EFFLUENT LIMITATIONS**

| Pollutant or pollutant property | Maximum for any 1 day | Average of daily values for 30 consecutive days |
|---------------------------------|-----------------------|---|
|                                 |                       | Milligrams per liter (mg/l)                     |
| TTO <sup>1</sup> .....          | 1.37                  | ( <sup>2</sup> )                                |

<sup>1</sup> Total toxic organics.  
<sup>2</sup> Not applicable.

(b) A new source submitting a certification in lieu of monitoring pursuant to § 469.13 (c) and (d) of this regulation must implement the solvent management plan approved by the control authority.

**§ 469.19 Effluent limitations representing the degree of effluent reduction attainable by the application of the best conventional pollution control technology (BCT).**

Except as provided in 40 CFR 125.30 through 125.32, any existing point source subject to this subpart must achieve the following effluent limitations representing the degree of effluent reduction attainable by the application of the best conventional pollution control technology (BCT):